Embedded Systems Design: A Unified Hardware/Software Introduction

Chapter 10: IC Technology

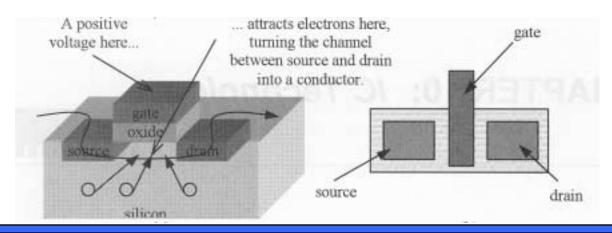
Outline

Anatomy of integrated circuits

- Full-Custom (VLSI) IC Technology
- Semi-Custom (ASIC) IC Technology
- Programmable Logic Device (PLD) IC Technology

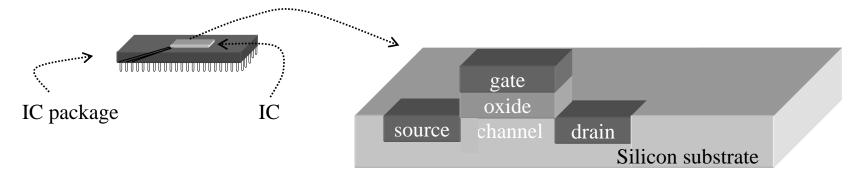
CMOS transistor

- Source, Drain
 - Diffusion area where electrons can flow
 - Can be connected to metal contacts (via's)
- Gate
 - Polysilicon area where control voltage is applied
- Oxide
 - Si O₂ Insulator so the gate voltage can't leak



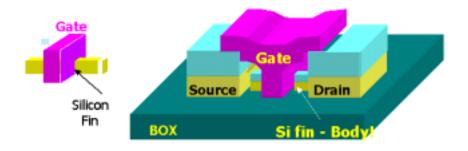
End of the Moore's Law?

- Every dimension of the MOSFET has to scale
 - (PMOS) Gate oxide has to scale down to
 - Increase gate capacitance
 - Reduce leakage current from S to D
 - Pinch off current from source to drain
 - Current gate oxide thickness is about 2.5-3nm
- That's about 25 atoms!!!



Proposed Structures: FinFET

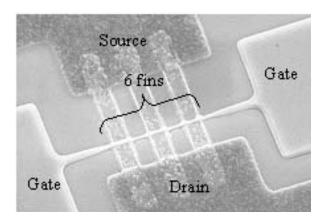
Body is a Thin Silicon Film Double Gate Structure + Raised Source Drain



X. Huang, et al, 1999 IEDM, p.67-70

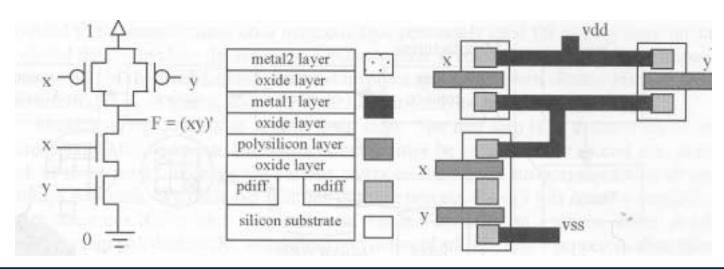
20Ghz +

- FinFET has been manufactured to 18nm
 - Still acts as a very good transistor
- Simulation shown that it can be scaled to 10nm
 - Quantum effect start to kick in
 - Reduce mobility by ~10%
 - Ballistic transport become significant
 - Increase current by about ~20%



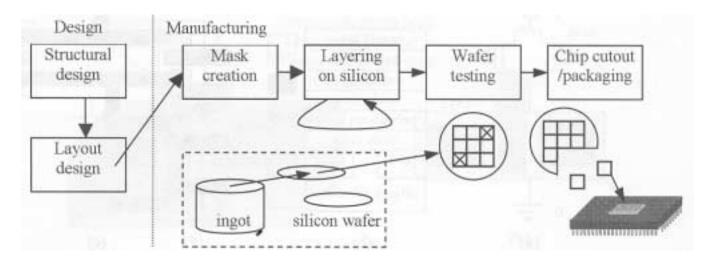
NAND

- Metal layers for routing (~10)
- PMOS don't like 0
- NMOS don't like 1
- A stick diagram form the basis for mask sets



Silicon manufacturing steps

- Tape out
 - Send design to manufacturing
- Spin
 - One time through the manufacturing process
- Photolithography
 - Drawing patterns by using photoresist to form barriers for deposition

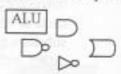


Full Custom

- Very Large Scale Integration (VLSI)
- Placement
 - Place and orient transistors
- Routing
 - Connect transistors
- Sizing
 - Make fat, fast wires or thin, slow wires
 - May also need to size buffer
- Design Rules
 - "simple" rules for correct circuit function
 - Metal/metal spacing, min poly width...

START

Designers create layouts for basic components.



Designers place the components, resulting in masks.



Designers provide the connections among components, which are translated to masks.



The masks are sent to the fabrication plant to produce ICs.

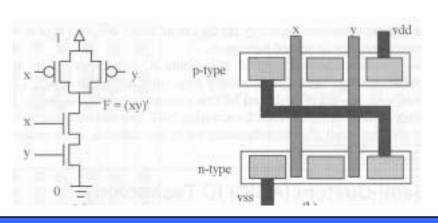


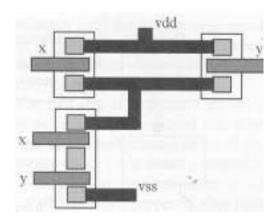
ICs are now ready to be tested/used.



Full Custom

- Best size, power, performance
- Hand design
 - Horrible time-to-market/flexibility/NRE cost...
 - Reserve for the most important units in a processor
 - ALU, Instruction fetch...
- Physical design tools
 - Less optimal, but faster...







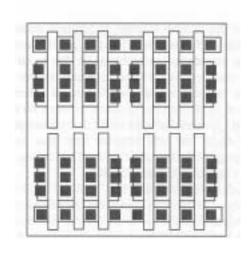
Semi-Custom

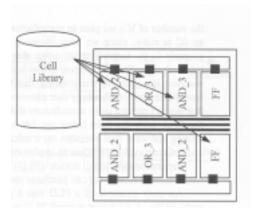
Gate Array

- Array of prefabricated gates
- "place" and route
- Higher density, faster time-to-market
- Does not integrate as well with full-custom



- A library of pre-designed cell
- Place and route
- Lower density, higher complexity
- Integrate great with full-custom





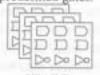
Semi-Custon

Most popular design style

- Jack of all trade
 - Good
 - Power, time-to-market, performance, NRE cost, per-unit cost, area...
- Master of none
 - Integrate with full custom for critical regions of design

Gate array

Designers are provided with a set of masks of predefined gates.



START

Designers provide the connections among gates, which are translated to masks.



The masks are sent to the fabrication plant to produce ICs.

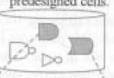


ICs are now ready to be tested/used



Standard cell

Designers are provided with a library of predesigned cells



START

Designers choose cells place and connect them resulting in masks.



Designers provide the connections among cells, which are translated to masks



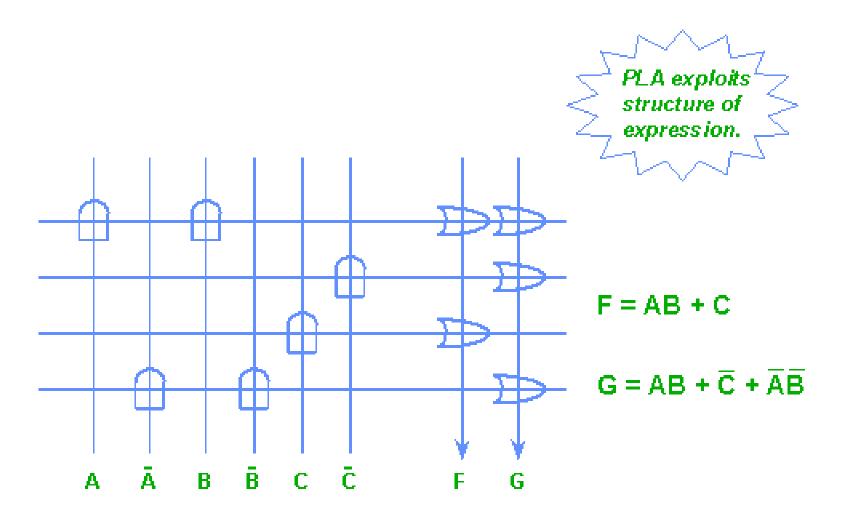
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Programmable Logic Array (PLA)



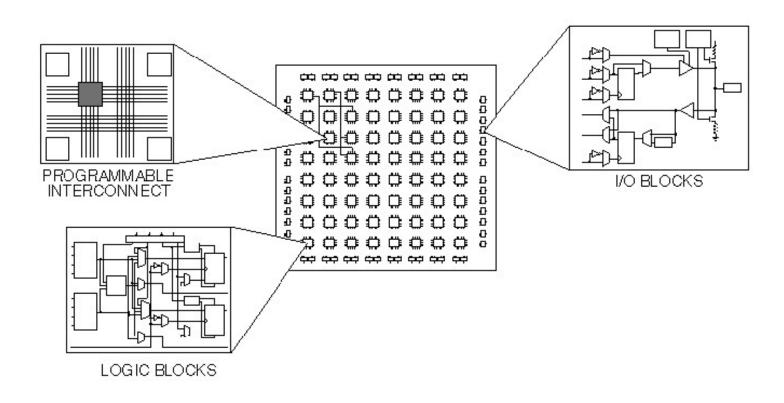
Programmable Logic Device

- Programmable Logic Device
 - Programmable Logic Array, Programmable Array Logic, Field Programmable Gate Array
- All layers already exist
 - Designers can purchase an IC
 - To implement desired functionality
 - Connections on the IC are either created or destroyed to implement
- Benefits
 - Very low NRE costs
 - Great time to market
- Drawback
 - High unit cost, bad for large volume
 - Power
 - Except special PLA
 - slower



1600 usable gate, 7.5 ns \$7 list price

Xilinx FPGA



Configurable Logic Block (CLB)

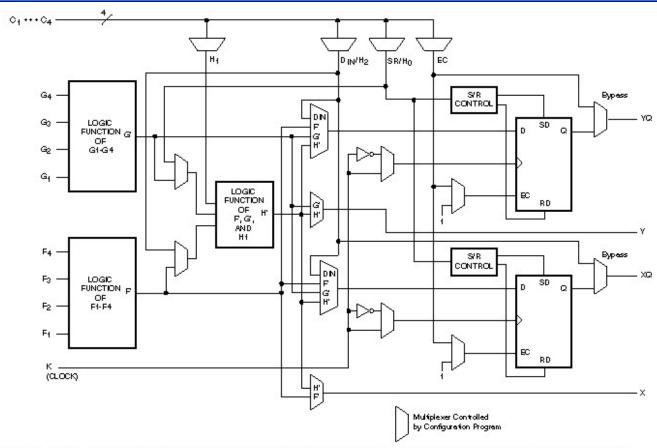
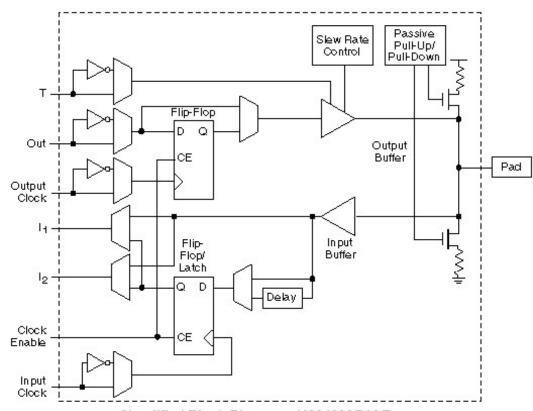


Figure 1: Simplified Block Diagram of XC4000-Series CLB (RAM and Carry Logic functions not shown)

I/O Block



Simplified Block Diagram of XC4000E IOB